



Docket No.: M4065.0704/P704 (PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Letters Patent of:

Kristy A. Campbell et al.

Patent No.: 6,955,940 12

Issued: October 18, 2005

For: METHOD OF FORMING CHALCOGENIDE

COMPRISING DEVICES

Of Correction

REQUEST FOR CERTIFICATE OF CORRECTION PURSUANT TO 37 CFR 1.322 & 1.323

Attention: Certificate of Correction Branch

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

Upon reviewing the above-identified patent, Patentee noted typographical errors which should be corrected.

In the Foreign Patent Documents portion of the References Cited Section, Applicants made the following error to be corrected:

"WO 97/488032" should read --WO 97/48032--.

In field (74) Attorney, Agent, or Firm, the PTO misspelled the name of the firm:

"Dickstein Shaprio Morin & Oshinsky LLP" should read --Dickstein Shapiro Morin & Oshinsky LLP--.

01/12/2006 SZEWDIE1 00000047 6955940

01 FC:1811 100.00 GP

DSMDB.2026449.1

In the Abstract, line 10, Applicants made the following error to be corrected:

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Also in the Other Publications portion of the References Cited section, Applicants made the following error to be corrected:

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In the Specification, Applicants made the following errors to be corrected:

Column 3, line 45, "example only, example" should read --example only,--;

Column 6, line 52, "comprises and oxide" should read --comprises an oxide--.

In the Claims, the PTO made the following error to be corrected:

Claim 13, column 9, line 17, "atomosphere" should read --atmosphere--.

and

The errors were made primarily by the PTO but were also found in the application as filed by applicant. Please charge our Credit Card in the amount of \$100.00 covering the fee set forth in 37 CFR 1.20(a). Credit Card Payment Form SB-2038, with a signature from an authorized cardholder, is enclosed.

The errors now sought to be corrected are inadvertent typographical errors the correction of which does not involve new matter or require reexamination.

Transmitted herewith is a proposed Certificate of Correction effecting such amendment. Patentees respectfully solicit the granting of the requested Certificate of Correction.

The Director is hereby authorized to charge any deficiency in the fees filed, asserted to be filed or which should have been filed herewith (or with any paper hereafter filed in this application by this firm) to our Deposit Account No. 04-1073, under Order No. M4065.0704/P704. A duplicate copy of this paper is enclosed.

Dated: January 18, 2006

Respectfully submitted,

By Thomas J. D'Amico

Registration No.: 28,371

Peter McGee

Registration No.: 35,947

DICKSTEIN SHAPIRO MORIN &

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PTO/SB/17 (12-04v2)
Approved for use through 7/31/2006. OMB 0651-0032
U.S. Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE

Under the Papery	respond to a collection	respond to a collection of information unless it displays a valid OMB control number.					
Effec	Complete if Known						
Fees pursuant to the Consoli	Application Number P		Patent#: 6,955,940 B 2				
FEE TR	Filing Date	- 1:	Issued: October 18, 2005				
Fo	First Named Inventor Kristy A. Campbell						
<u> </u>	Examiner Name D. Vu		D. Vu				
Applicant claims sn	Art Unit 2818						
TOTAL AMOUNT OF PAYMENT (\$) 100.00			Attorney Docket	Docket No. M4065.0704/P704			
METHOD OF PAYMENT (check all that apply)							
Check X Credit Card Money Order None Other (please identify):							
Deposit Account Deposit Account Number: 04-1073 Deposit Account Name: Dickstein Shapiro Morin & Oshinsky LLP							
For the above-identified deposit account, the Director is hereby authorized to: (check all that apply)							
X Charge fee(s) indicated below Charge fee(s) indicated below, except for the filing fee							
Charge any additional fee(s) or underpayment of fee(s) under 37 CFR 1.16 and 1.17							
FEE CALCULATION							
1. BASIC FILING, SEARCH, AND EXAMINATION FEES							
	FILIN	IG FEES SE	ARCH FEES	EXAMIN	ATION FEES		
Application Type	Fee (\$)	Small Entity Fee (\$) Fee (Small Entity \$) Fee (\$)	Fee (\$)	Small Entity Fee (\$)	Fees Paid (\$)	
Utility	300	150 500		200	100	1 000 1 did (\$7	
Design	200	100 100		130	65		
Plant	200	100 300		160	80		_
Reissue	300	150 500		600	300		
Provisional	200	100		0	0		_
2. EXCESS CLAIM FEES Small E							 ntity
Fee Description						Fee (\$) Fee (\$	
Each claim over 20 (including Reissues)						50 2:	.5
Each independent claim over 3 (including Reissues)						200 100	0
Multiple dependent clair	ms					360 186	0
Total Claims Ex	Extra Claims Fee (\$) Fee Paid (\$)			<u>M</u> 1	Multiple Dependent Claims		
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-=	× _	<u> </u>					
3. APPLICATION SIZE FEE							
If the specification and drawings exceed 100 sheets of paper (excluding electronically filed sequence or computer listings under 37 CFR 1.52(e)), the application size fee due is \$250 (\$125 for small entity) for each additional 50							
sheets or fraction thereof. See 35 U.S.C. 41(a)(1)(G) and 37 CFR 1.16(s).							
Total Sheets	Extra Sheets		additional 50 or fra		f Fee (\$)	Fee Paid (\$)	
4. OTHER FEE(S)							
Non-English Specification, \$130 fee (no small entity discount)							•
Other (e.g., late filing surcharge): 1811 Certificate of correction 100.00							
SUBMITTED BY							
Signature	, h	\swarrow	Registration No.	28,371	Telephone	(202) 828-2232	
Name (Print/Type) Thoma	as I D'Amirro	g	(Attorney/Agent)	,-,-	Date	January 40, 2006	

UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

Page 1 of 3

PATENT NO.

6,955,940 BZ

APPLICATION NO.

09/943,199

ISSUE DATE

October 18, 2005

INVENTOR(S)

Kristy A. Campbell et al.

It is certified that errors appear in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

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MAILING ADDRESS OF SENDER (Please do not use customer number below): Thomas J. D'Amico DICKSTEIN SHAPIRO MORIN & OSHINSKY LLP 1 2101 L Street NW Washington, DC 20037-1526

"Cahen, D.; Gilet, J.-M.; Schmitz, C.; Chernyak, L.; Gartsman, K.; Jakubowicz, A., Room-Temperature, electric field induced creation of stable devices in CulnSe2 Crystals, Science 258 (1992) 271-274."

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